

FORM PTO-1449 (REV. 7-80)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. RD-28,965		SERIAL NO.	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT <u>LIST OF ITEMS</u>				Applicant Marc (NMN) Schaepkens			
				Filing Date		Group	
U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL	DOCUMENT NUMBER		DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
/EB/	A1	4,871,580	10/3/89	Schram et al.			
/EB/	A2	6,110,544	8/29/00	Yang et al.			
	A3						
	A4						
	A5						
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
	B1						
	B2						
OTHER INFORMATION (Including Author, Title, Date, Pertinent Pages, etc.)							
/EB/	C1	Application Serial No. 09/681,820, filed June 11, 2001, "Apparatus and Method for Large Area Chemical Vapor Deposition Using Multiple Expanding Thermal Plasma Generators".					
	C2	Application Serial No. 09/836,657, filed April 17, 2001, "A Transparent Flexible Barrier for Liquid Crystal Display Devices and Method of Making the Same.					
	C3	Application Serial No. 09,683,148, filed November 27, 2001, "Apparatus and Method for Depositing Large Area Coatings on Non-Planar Surfaces".					
	C4	Application Serial No. 09,683,149, filed November 27, 2001, "Apparatus and Method for Depositing Large Area Coatings on Planar Surfaces".					
	C5	Philips Research Passport, "Flexible Displays Cast Off Rigid Constraints", Dr. Peter Slikkerveer, Issue 10, Issue 10, pp 5-7, January 2002.					
	C6	Appl. Phys. Letter, "Etch Mechanism in the Refractive Index Silicon Nitride Plasma-Enhanced Chemical Vapor Deposition Process, Yeo Kuo, Volume 63, No. 2, pp 144-146, July 12, 1993					
✓	C7	American Vacuum Society, "Transparent Barrier Coatings on Polyethylene Terephthalate By Single- and Dual-Frequency Plasma-Enhanced Chemical Vapor Deposition", A. S. da Silva Sobrinho et al, A, Volume 16, No. 6, pp 3190-3198, Nov/Dec 1998.					
	C8						
EXAMINER /Elizabeth Burkhart/					DATE CONSIDERED 11/19/2007		
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant							

FORM PTO-1449 (REV. 7-80)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. RD-28,965-1		SERIAL NO.	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT <u>LIST OF ITEMS</u>				Applicant Marc Schaepekens			
				Filing Date 5/23/02		Group Art Unit 1775	
U.S. PATENT DOCUMENTS & PATENT APPLICATION PUBLICATION							
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
	A1						
	A2						
	A3						
	A4						
	A5						
	A6						
	A7						
	A8						
	A9						
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
/EB/	B1	WO 01/81649	1NOV01	PCT			X
/EB/	B2	EP0460966	11DEC91	European			X
/EB/	B3	FR 2712310	19MAY95				
OTHER INFORMATION (Including Author, Title, Date, Pertinent Pages, etc.)							
/EB/	C1	Osamu Fukumasa, "Synthesis of New Ceramics From Powder Mixtures Using Thermal Plasma Processing", Elsevier, Thin Solid Films, 390, pages 37-43, 2001.					
	C2						
	C3						
	C4						
	C5						
	C6						
	C7						
	C8						
EXAMINER					DATE CONSIDERED		
/Elizabeth Burkhardt/					11/19/2007		
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant							